## Supporting Information

## Switching Photodiodes Based on (2D/3D) PdSe<sub>2</sub>/Si Heterojunctions with a Broadband Spectral Response

Sikandar Aftab<sup>1\*</sup>, Ms. Samiya<sup>2</sup>, Wugang Liao<sup>3</sup>, Muhammad Waqas Iqbal<sup>4</sup>, Mavra Ishfaq<sup>5</sup>, Karna Ramachandraiah<sup>6</sup>, Hafiz Muhammad Salman Ajmal<sup>7</sup>, Hafiz Mansoor Ul Haque<sup>4</sup>, Saqlain Yousaf<sup>8</sup>, Zaheer Ahmed<sup>9</sup>, Muhammad Usman khan<sup>10</sup>, Atteq Ur Rehman<sup>11</sup> Muhammad Zahir

## Iqbal<sup>12</sup>

<sup>1</sup>Department of Engineering Science, Simon Fraser University, Burnaby, BC, Canada

<sup>2</sup>Department of Environment and Energy, Sejong University, 209 Neungdong-ro, Gwangjin-gu, Korea

<sup>3</sup>College of Electronic and Information Engineering, Shenzhen University, Shenzhen 518060, Peoples's Republic of China

<sup>4</sup>Department of Physics, Riphah International University, 14 Ali Road, Lahore, Pakistan

<sup>5</sup>Faculty of Natural Sciences, Department of Physics, The University Of Lahore, (Gujrat

Campus)-50700, Punjab, Pakistan

<sup>6</sup>Scholl of Life Sciences, Sejong University, Seoul 05006, Korea

<sup>7</sup>Division of Electronics and Electrical Engineering, Dongguk University, Seoul 100-715, Korea

<sup>8</sup>Department of Physics, Sungkyunkwan University, Suwon, 440-746, South Korea

<sup>9</sup> Department of Biochemistry, University of Agriculture, Faisalabad Pakistan

<sup>10</sup>Department of Electronics Science and Technology, Harbin Institute of Technology, Harbin 150080, China

<sup>11</sup>King Abdullah University of Science and Technology (KAUST), Thuwal 23955-6900, Kingdom of Saudi Arabia of Electronics Science.

<sup>12</sup>Nanotechnology Research Laboratory, Faculty of Engineering Sciences, GIK Institute of Engineering Sciences and Technology, Topi 23640, Khyber Pakhtunkhwa, Pakistan

E-mail: aftab\_sikandar@sfu.ca, physics.sikandar@gmail.com



**Figure S1.**  $({}^{I}_{ds} - {}^{V}_{ds})$  characteristics of the n- ${}^{PdSe_2/p}$ -Si diode of the same device before and after vacuum annealing at various annealing temperatures.



**Figure S2.** Gate-dependent rectifying effect of the  $PdSe_2/Si$  mix-dimensional heterojunction p - n diode in the log scale show change in the rectification ratio with respect to ionic liquid top gate voltage.



**Figure S3.** Rectifying effect at zero top gate voltage of the  $PdSe_2/Si$  mix-dimensional heterojunction p - n diode at different thickness of  $PdSe_2$  flakes.



**Figure S4.** Photoresponse of n- $PdSe_2$ /p-Si diode with  $\lambda$ = 600 nm for 62.3 mw/cm<sup>2</sup> (a) showing fitting for rise time and (b) for decay time.



Figure S5. The I<sub>ds</sub>-V<sub>ds</sub> curves of the PdSe<sub>2</sub>/Si heterojunction diode under dark and illumination of light  $\lambda$ = 600 nm which shows the photovoltaic behaviors at a power intensity of 35.1 mW/cm<sup>-2</sup>.